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February 20, 2004

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TO Examiner Thornton
COMPANY U.S. PTO
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FROM: Michael R. Hull EXTENSION: 837
Marshall, Gerstein & Borun LLP
PAGES (INCLUDING THIS PAGE): 5 CLIENT NO: 30205
MATTER NO: 37456
PLEASE CONFIRM RECEIPT: No COUNTRY CODE: US
MESSAGE: Re: U.S. Patent Application Serial No. 09/884,313

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PATENT
30205/37456

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Geun Su Lee et al.

Serial No.: 09/884,313

Filed: June 19, 2001

For: Photoresist Polymer for Top-
Surface Imaging Process by Silylation
and Photoresist Composition
Containing the Same

Group Art Unit: 1752

Examiner: Yvette C. Thornton

I hereby certified that this paper and the
papers referred to as attached herein are
being transmitted, via facsimile, to
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February 20, 2004


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SECOND AMENDMENT AFTER FINAL (37 C.F.R. § 1.116)

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

In response to the final office action mailed on October 20, 2003 and our
response to the teleconferences between the undersigned and Examiner Thornton on
February 9 and 19, 2004, please amend the above-identified patent application as
follows: